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	Application No.	Application No. Applicant(s)	
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Notice of Allowability	Examiner	Art Unit	1
	Kevin M. Picardat	2822	Ph/
The MAILING DATE of this communication appeals all claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R	(OR REMAINS) CLOSED in or other appropriate comming IGHTS. This application is:	n this application. If not include unication will be mailed in due of	ed course. <b>THIS</b>
1. This communication is responsive to papers filed on 17 Me	arch 2004.		
2. The allowed claim(s) is/are <u>1-20</u> .			
3. $\boxtimes$ The drawings filed on <u>17 March 2004</u> are accepted by the	Examiner.		
<ul> <li>4. Acknowledgment is made of a claim for foreign priority una)</li> <li>All b)</li> <li>Some* c)</li> <li>None of the:</li> <li>1. Certified copies of the priority documents have</li> <li>2. Certified copies of the priority documents have</li> <li>3. Copies of the certified copies of the priority documents have</li> <li>International Bureau (PCT Rule 17.2(a)).</li> <li>* Certified copies not received:</li> </ul>	e been received. e been received in Application	on No	ion from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the req	uirements
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give			OTICE OF
6. ☐ CORRECTED DRAWINGS ( as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftspers		w / RTO 048) attached	
1) ☐ hereto or 2) ☐ to Paper No./Mail Date	Soll's I atent Diawing Nevier	W (F10-540) attached	
(b) ☐ including changes required by the attached Examiner' Paper No./Mail Date	s Amendment / Comment o	r in the Office action of	
Identifying Indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t			back) of
7. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT			lote the
Attachment(s)  1. ☑ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)		formal Patent Application (PTC ummary (PTO-413),	)-152)
	Paper No.	/Mail Datè ´	
Information Disclosure Statements (PTO-1449 or PTO/SB/C     Paper No./Mail Date	_	Amendment/Comment	
Examiner's Comment Regarding Requirement for Deposit     Proceedings Metarial		Statement of Reasons for Allov	wance
of Biological Material	9.	Kryin W. Pleardat Prinary Exeminar	

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The following is an examiner's statement of reasons for allowance: None of the prior teaches or suggests vertical semiconductor device or method of making including providing a semiconductor substrate comprising a semiconductor material, forming a deep trench in the semiconductor substrate, depositing a first gate dielectric layer on a side wall of the deep trench, filling the deep trench with a filling material, forming a first source/drain region and a second source/drain region around and along the depth of the deep trench, forming first and second shallow trench isolation regions sandwiching the deep trench in an active region, the first and second shallow trench isolation regions abutting the active region via first and second abutting surfaces, respectively, wherein the first and second abutting surfaces are parallel to each other and are perpendicular to an orientation plane of the semiconductor material of the substrate, removing the first gate dielectric layer so as to expose the semiconductor material in the deep trench to the atmosphere, chemically etching the exposed semiconductor material in the deep trench, depositing a second gate dielectric layer on a side wall of the deep trench, and forming a gate terminal for the vertical semiconductor structure in the deep trench.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kevin M. Picardat whose telephone number is 571-272-1841. The examiner can normally be reached on Monday-Thursday 7:00-5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on 571-272-1852. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Kevin M. Picardat Primary Examiner Art Unit 2822